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Terahertz transmission characteristics of high-mobility GaAs and InAs two-dimensional-electron-gas systems

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Frequency-dependent complex conductivity of high-mobility GaAs and InAs two-dimensional-electron-gas (2DEG) systems is studied by terahertz time domain spectroscopy. Determining the momentum relaxation time from a Drude model, the authors find a lower value than that from dc measurements, particularly at high frequencies/low temperatures. These deviations are consistent with the ratio τ_t/τ_q , where τ_q is the full scattering time. This suggests that small-angle scattering leads to weaker heating of 2DEGs at low temperatures than expected from dc mobility. © 2006 American Institute of Physics. [DOI: 10.1063/1.2357605]

There is significant interest in developing terahertz sources and detectors that utilize high-mobility two-dimensional-electron-gas (2DEG) systems.¹⁻⁶ In this letter, we therefore use terahertz time domain spectroscopy (TDS) to measure the ac conductivity of GaAs and InAs 2DEGs. Terahertz TDS allows for contactless measurement of the frequency-dependent ($\sim 5-85 \text{ cm}^{-1}$) complex conductivity by coherently detecting the transmitted amplitude and phase shift of a laser-generated electric-field pulse. In such studies, it is often assumed that free-carrier absorption is described by a Drude model, using the relaxation time obtained from dc transport. The optical conductivity of metal films has been found to be best described by a “modified Drude model,” however, that incorporates a *frequency-dependent* scattering time.⁷ A similar model has also been used in studies of terahertz conductivity in transient photoconductivity of bulk GaAs.⁸

In this letter, we show that a modified Drude model fits the measured terahertz complex conductivity of GaAs and InAs 2DEGs, with relaxation times (τ_{THz}) shorter than those from dc mobility μ , which yields the mobility lifetime τ_t . This discrepancy is increasingly pronounced with decreasing temperature (T). Near 4.2 K, our analysis suggests that τ_{THz} is actually intermediate between τ_t and the quantum lifetime τ_q , which defines the total-scattering rate, extracted from analysis of the Shubnikov-de Haas (SdH) effect. We suggest that, due to the role of *small-angle* scattering, Drude heating

of high-mobility 2DEGs by terahertz radiation can be significantly weakened at low T , compared to estimates based on dc transport. These results are therefore relevant for terahertz photonic-device development since they reveal that one cannot use dc transport to infer free-carrier loss.

In terahertz TDS, the sample transmission is referenced to that of a substrate (we use a piece of the same heterostructure with its 2DEG layer removed by etching). Its complex conductivity is then related to the transmission characteristics by the thin-film approximation,⁹

$$t = \frac{E_{\text{film}} e^{i\varphi_{\text{film}}}}{E_{\text{sub}} e^{i\varphi_{\text{sub}}}} = \frac{t_{\text{film}}}{t_{\text{sub}}} = \frac{1 + n_{\text{sub}}}{1 + n_{\text{sub}} + Z_0 \sigma_s}, \quad (1)$$

where

$$\sigma_s = \sigma_s^{(1)} + i\sigma_s^{(2)}, \quad \text{Re} \left[\frac{1}{t} \right] = 1 + \frac{Z_0 \sigma_s^{(1)}}{1 + n_{\text{sub}}},$$

$$\text{Im} \left[\frac{1}{t} \right] = \frac{Z_0 \sigma_s^{(2)}}{1 + n_{\text{sub}}}.$$

Here, E_{film} (E_{sub}) is the magnitude of the electric field transmitted by the film (substrate), t_{film} (t_{sub}) is the complex terahertz transmission of the film (substrate), Z_0 is the characteristic impedance of free space ($\sim 377 \Omega$), and n_{sub} [=3.3 for GaAs (Ref. 10)] is the refractive index of the substrate. In the modified Drude model, the complex ac conductivity at frequency ω ,¹¹

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TABLE I. Summary of the key parameters of the GaAs and InAs 2DEG samples.

	Hall n_s at 300 K (10^{15} m^{-2})	Hall n_s at 4.2 K (10^{15} m^{-2})	SdH n_s at 4.2 K (10^{15} m^{-2})	μ at 300 K ($\text{cm}^2/\text{V s}$)	μ at 4.2 K ($\text{cm}^2/\text{V s}$)	τ_i at 4.2 K (ps)	τ_q at 4.2 K (ps)	τ_i/τ_q at 4.2 K
GaAs	8.1	2.3	2.3	7000	2 000 000	76	0.14	540
InAs	84	79	$36^a, 26^b$	21 000	450 000	1.4	0.10	14

^aDensity due to first 2DEG subband.^bDensity due to second 2DEG subband.

$$\sigma_s = \frac{n_s e^2 \tau}{m^*(\omega) (1 - i\omega\tau(\omega))}, \quad (2)$$

where n_s is the 2DEG carrier density, $m^*(\omega)$ is the frequency-dependent effective mass, and $\tau(\omega)$ is the frequency-dependent relaxation time. A strength of terahertz TDS is that one can directly extract $\tau(\omega)$ (which we will refer to hereafter as τ_{THz}), independent of $m^*(\omega)$ and n_s ,

$$\tau_{\text{THz}} = \frac{\sigma_s^{(2)}}{\omega \sigma_s^{(1)}} = \frac{1}{\omega} \frac{\text{Im}(1/t)}{[\text{Re}(1/t) - 1]}. \quad (3)$$

GaAs and InAs 2DEGs were investigated in this study. The GaAs 2DEG is comprised of a 10 nm undoped GaAs cap layer, 98 nm of undoped AlGaAs, 2 nm of undoped AlAs, 2.3 nm of undoped GaAs, a Si delta-doped layer with an areal density of 10^{12} cm^{-2} , 0.6 nm of undoped GaAs, 2 nm of undoped AlAs, a 75 nm AlGaAs spacer layer, a 30 nm GaAs quantum well, a 95 nm AlGaAs lower spacer layer, 2 nm of undoped AlAs, 2.3 nm of undoped GaAs, a lower Si delta-doped layer with an areal density of 10^{12} cm^{-2} , 0.6 nm of undoped GaAs, 2 nm of undoped AlAs, 98 nm of undoped AlGaAs, 300 periods of a GaAs/AlGaAs smoothing superlattice, and a 100-nm-thick undoped GaAs buffer. The InAs 2DEG (Ref. 12) was grown on GaAs and was comprised of a 6 nm GaSb cap layer, 25 nm of undoped AlSb, a Te delta-doped layer, a 15 nm undoped AlSb spacer layer, a 15 nm InAs quantum well, a 15 nm AlSb spacer layer, a Te delta-doped layer, a 20 nm undoped AlSb layer, ten periods of a 2.5 nm AlSb/2.5 nm GaSb smoothing superlattice, and undoped buffer layers of 2.5 nm AlSb, 100 nm AlAs, and 200 nm GaAs. For transport measurements, GaAs Hall bars with alloyed contacts were formed by optical lithography and lift-off. The InAs 2DEG was cleaved into small pieces and alloyed contacts were formed by In soldering.

SdH and Hall effects were measured in the GaAs and InAs 2DEGs at 1.4–40 K. These measurements were made by standard lock-in techniques and yield information on the T dependence of τ_i . An analysis of the SdH oscillations also allows τ_q to be determined.¹³ Table I lists the parameters extracted for the 2DEGs. The different n_s extracted for InAs from the SdH and Hall effects indicate partial filling of a second subband. Due to nonparabolicity of the InAs conduction band, the dc effective mass was extracted from the temperature dependence of the SdH oscillations.¹³ This gave $m^* = 0.06m_0 \pm 0.005m_0$, in good agreement with the predictions of the Kane model for this density.¹⁴ The main uncertainty in our analysis is in our estimate of τ_q . The error bars in Fig. 3 show the range of τ_q obtained from our analysis, but even after considering this uncertainty there is still some (a factor of 2) discrepancy between the turn-on field of the SdH

oscillations and the low-temperature value of τ_q . This does not change the quantitative conclusions of our work, however.

Terahertz TDS (Fig. 1) was performed in a cryostat system cooled to 10 K. The system uses transient current generation from an antenna on semi-insulating GaAs and electro-optic detection. A 65 fs, 350 mW, and 82 MHz Ti:sapphire laser was used to generate/detect the terahertz pulse. The cryostat has two sets of terahertz-transparent polyethylene windows in the path of the terahertz beam. The scan resolution was 0.02 THz and the time-domain data were Fourier transformed to give the magnitude/phase of the transmitted field for the sample and reference substrate. The bandwidth is 2.5 THz, but since the absorbance falls off dramatically above 0.5 THz we emphasize here the range over which the frequency dependence is apparent. Transmission ($|t|$) and phase [$\tan^{-1}(\text{Im}(t)/\text{Re}(t))$] of the InAs and GaAs 2DEGs are shown in Fig. 1. These data are plotted as discrete points, and are averaged values calculated over a 0.1 THz window. The high n_s of the InAs 2DEG is responsible for its stronger absorption (particularly below 1 THz) compared to the GaAs system.

Figure 2 shows the frequency dependence of τ_{THz} [from Eq. (3)] for the 2DEGs at several temperatures. At 300 K, τ_{THz} appears to be independent of frequency. At lower tem-

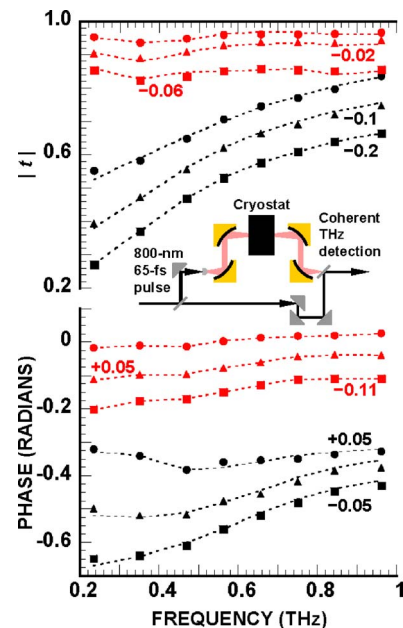


FIG. 1. (Color online) Field transmission magnitude (upper panel) and phase (lower panel) of the GaAs (red data) and InAs (black data) 2DEGs. The solid symbols are the original experimental data. The dotted lines are fits to Eq. (2) using the variation of τ_{THz} inferred from the thin-film approximation [Eq. (3)]. Circles: 300 K, triangles: 125 K, and squares: 20 K. Inset: schematic of the key features of the terahertz TDS system.

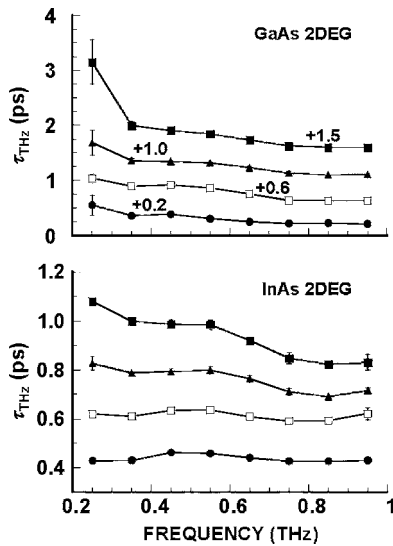


FIG. 2. Frequency dependence of τ_{THz} inferred from the thin-film approximation [Eq. (3)]. Circles: 300 K, open squares: 200 K, triangles: 125 K, and filled squares: 20 K. The solid lines are interpolated between data points.

peratures, however, τ_{THz} shows a significant decrease with increasing frequency. Similar behavior has been reported in midinfrared measurements of metal films.⁷ In Fig. 1, we have substituted the frequency-dependent values of τ_{THz} into Eq. (2) to calculate the transmission amplitude/phase and we plot these results as the dotted lines. We have used $m_{\text{InAs}}^* = 0.06m_0$ and $m_{\text{GaAs}}^* = 0.067m_0$ in these calculations, along with the total 2DEG densities (Table I). The fits show good agreement with experiment, with small deviations arising from the frequency dependence in the effective mass.

Figure 3 shows the various lifetimes obtained from our measurements. Near 300 K, the dc mobility is limited predominantly by electron-phonon scattering.¹⁵ As the temperature is lowered below this, the values of τ_t and τ_{THz} differ significantly. This is clearest for the GaAs 2DEG in which, at the lowest temperatures, τ_{THz} is several orders of magnitude smaller than τ_t but close to τ_q .¹⁶ The difference between τ_q and τ_t in such 2DEGs is known¹⁶ to result from the predominance of small-angle scattering at low-temperatures, which does not significantly limit the mobility. The large ratio of τ_t/τ_q in the GaAs 2DEG is due to its thick spacer layers. The suggestion therefore is that at low temperatures, small-angle scattering results in reduced terahertz absorption, relative to the value expected from the dc mobility.

Previously, the modified Drude model was shown to agree well with terahertz measurements of bulk GaAs.⁸ Our analysis suggests a different picture to describe the interaction of terahertz radiation with a high-mobility 2DEG. Near 300 K, where electron-phonon scattering should dominate the mobility,¹⁵ the results of our experiment approach the predictions of the dc Drude model. At low T , however, where impurity scattering dominates, large-angle scattering predominantly limits the dc mobility while the terahertz transmission seems to be sensitive to the *total-scattering* (τ_q) rate, particularly above ~ 0.5 THz. Since τ_t/τ_q can be very large (>100 for GaAs), low-temperature Drude heating of 2DEGs by terahertz radiation can be significantly weaker than simple estimates based on the 2DEG mobility. Our measurements of the InAs 2DEG are consistent with this idea. The ratio τ_t/τ_q for this 2DEG is nearly 40 times smaller than that

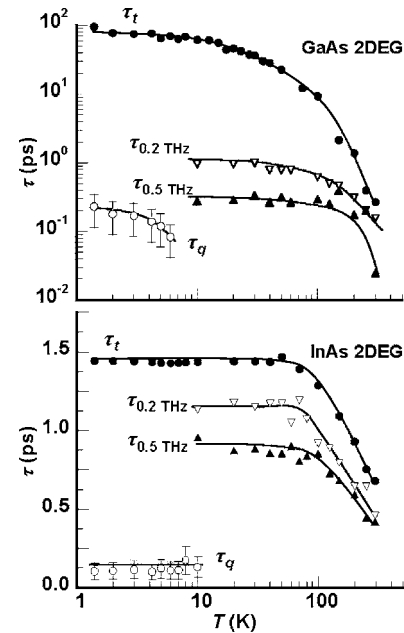


FIG. 3. Temperature dependence of τ_{THz} , τ_t , and τ_q in the GaAs (upper) and InAs (lower) 2DEGs. The solid lines are guides for the eyes.

in GaAs (see Table I), and the discrepancy between τ_{THz} and τ_t is also less pronounced (Fig. 3). The smaller value of τ_t/τ_q reflects the fact that the InAs 2DEG has no spacer layers and is unintentionally doped by donors that are believed to be located close to the interfaces of the quantum well.

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